

ionGUN

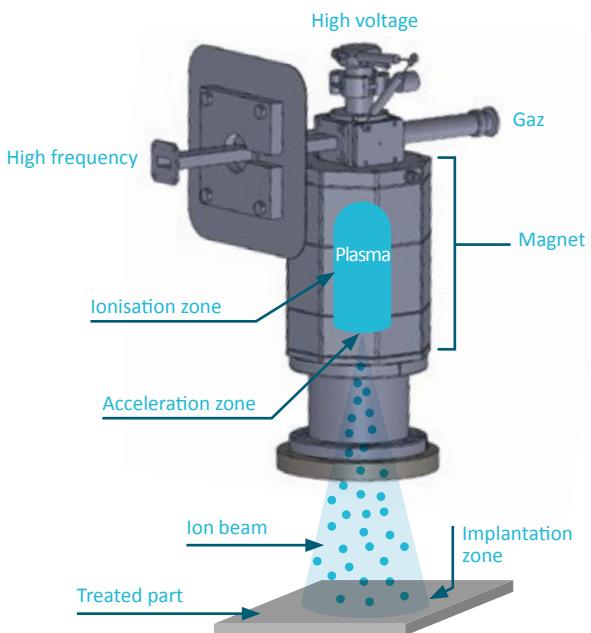
ion implantation technology



ionGUN : industrial ion implantation technology for surface enhanced performances

Benefits

- ▲ Physical cold processes
- ▲ Enhance surface properties without any coatings
- ▲ One technology for any materials
- ▲ No dimensional modification
- ▲ Environment friendly process
- ▲ Cheap operating costs



Features

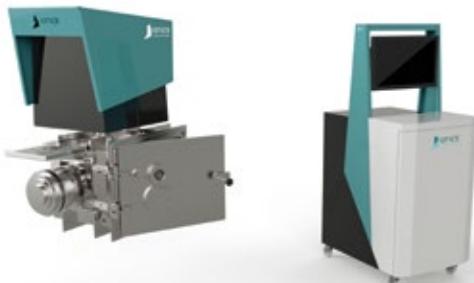
- ▲ Localised surface treatment Ø 100 mm
- ▲ Surface modification up to 5 µm
- ▲ Compact and robust design for industrial requirements
- ▲ Plug and play system on low pressure chamber
- ▲ Any gases : Ar, He, N₂, O₂, SiH₄

Options

- ▲ Charges neutralizer for insulating materials
- ▲ Additional pumping unit (PVD system)
- ▲ Full automated and integrated systems on demand

TECHNICAL DATA

High frequency power supply	10GHz / 50W
High voltage power supply	Power : up to 600W Ion energy : up to 40 kV Ion current : up to 15 mA
Gas flow	From 10 to 200 µlN/min
Magnetic field	0,5 Tesla
Connection	160 Ø flange
Water cooling system	yes



Fully automated with external control desk

